

WHAT IS CLAIMED IS:

1. A specimen surface level adjusting method used  
in a pattern inspecting apparatus for inspecting a  
pattern on a specimen surface on the basis of a  
5 detected image obtained by projecting inspecting light  
onto the specimen surface, the specimen surface level  
adjusting method comprising:

projecting level measuring light onto the specimen  
surface;  
10 detecting the position of the measuring light  
reflected on the specimen surface;  
calculating the level of the specimen surface on  
the basis of the position of the optical axis;  
adjusting the level of the specimen surface so  
15 that the calculated level may be held within the depth  
of focus of a pattern inspecting optical system;  
detecting the intensity of the reflected light;  
and  
fixing the specimen surface to a reference level,  
20 if the intensity is less than a specific threshold  
value.

2. The specimen surface level adjusting method  
according to claim 1, wherein the measuring light is  
projected diagonally onto the specimen surface.

25 3. The specimen surface level adjusting method  
according to claim 1, wherein the reference level is  
the level immediately before the specimen surface is

fixed.

4. The specimen surface level adjusting method according to claim 1, wherein the reference level is the average value of the level in a specific period of time before the specimen surface is fixed.

5. The specimen surface level adjusting method according to claim 1, wherein the reflected light is caused to enter an optical sensor including a plurality of photoelectric conversion elements, and

at least one of the position of the optical axis and the intensity is detected by monitoring the photoelectric conversion output of each of said plurality of photoelectric conversion elements.

6. The specimen surface level adjusting method according to claim 1, wherein

a specimen having the specimen surface is placed on a piezoelectric element, and the level of the specimen surface is adjusted by a voltage applied to the piezoelectric element.

7. A specimen surface level adjusting method used in a pattern inspecting apparatus for inspecting a pattern on a specimen surface on the basis of a detected image obtained by projecting inspecting light onto the specimen surface, the specimen surface level adjusting method comprising:

projecting first measuring light for level

measurement onto the whole of the specimen surface;

detecting the intensity of the reflected light of  
the first measuring light;

5 recording position information about projected  
position where the intensity is less than a specific  
threshold value;

projecting second measuring light for level  
measurement onto the specimen surface;

10 detecting the position of the optical axis of the  
reflected light of the second measuring light;

calculating the level of the specimen surface on  
the basis of the position of the optical axis;

15 adjusting the level of the specimen surface so  
that the calculated level may be held within the depth  
of focus of a pattern inspecting optical system; and

fixing the level of the specimen surface to a  
reference level at the projected position corresponding  
to the recorded position information.

20 8. The specimen surface level adjusting method  
according to claim 7, wherein the first and second  
measuring lights are projected from a single light  
source diagonally onto the specimen surface.

25 9. The specimen surface level adjusting method  
according to claim 7, wherein the reference level is  
the level immediately before the specimen surface is  
fixed.

10. The specimen surface level adjusting method

according to claim 7, wherein the reference level is the average value of the level in a specific period of time before the specimen surface is fixed.

5 11. The specimen surface level adjusting method according to claim 7, wherein

the reflected lights of the first and second measuring lights are caused to enter an optical sensor including a plurality of photoelectric conversion elements, and

10 at least one of the position of the optical axis and the intensity is detected by monitoring the photoelectric conversion output of each of said plurality of photoelectric conversion elements.

15 12. The specimen surface level adjusting method according to claim 7, wherein

a specimen having the specimen surface is placed on a piezoelectric element, and

the level of the specimen surface is adjusted by a voltage applied to the piezoelectric element.